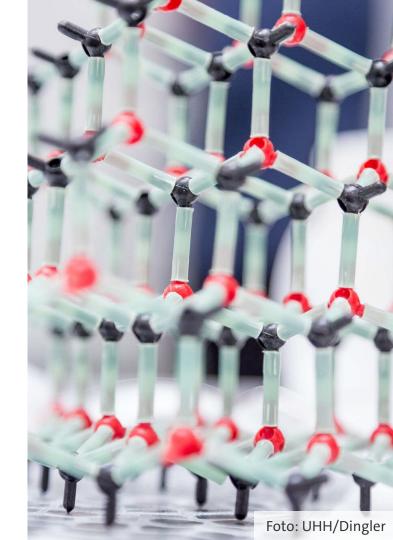


Open Day of Technology Platforms

Technology Platform – Clean Room @ CHyN

31.01.2024 Michael Rübhausen

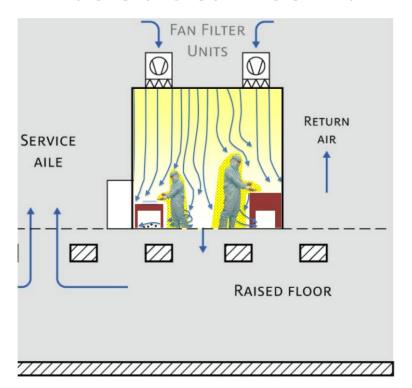


Concept of the platform

- Cutting edge technologies for mordern hybrid nanostructures
- Focussed Ion Beam, E-Beam Lithography, Optical Lithography, Reactive Ion Etching, Nanoimprinting, PVD techniques and many more
- More than 18 different devices are combined in typically 3-10 different process steps to make and characterize nano- and micros structures leading to diverse opportunities for research



What is a clean room?



Concentration max allowed of particles (particles/m³ of air)
Particles sizes equal or superior to that given below

(0.5um particles/ft³ of

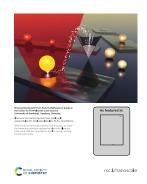
	Class ISO	0.1 μm	0.2 μm	0.3 μm	0.5 μm	1 μm	5 μm	Class US FS209
	ISO 1	10	2	0	0	0	0	
	ISO 2	100	24	10	4	0	0	
	ISO 3	1 000	237	102	35	8	0	1
	ISO 4	10 000	2 370	1 020	352	83	0	10
٠	ISO 5	100 000	23 700	10 200	3 520	832	29	100
1	ISO 6	1 000 000	237 000	102 000	35 200	8 320	293	1 000
	ISO 7				352 000	83 200	2 930	10 000
1	ISO 8				3 520 000	832 000	29 300	100 000
	ISO 9	0		0	35 200 000	8 320 000	293 000	

Standard ISO 14644-1

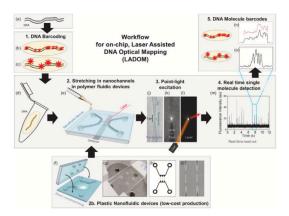
We are aiming at ISO class 4!

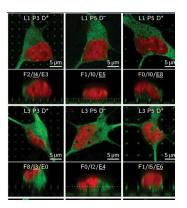


Applications – Some Examples

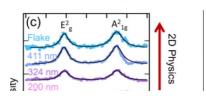


- Ouantum Nano Materials
- Bio-Hybrid Nano Materials
- Semiconductor Devices, Science, and Technology
- X-Ray Optics and X-Ray Devices
- Nanofluidic Devices and Detection
- Quantum Information





Confined in Space





You need training before you can enter!

- General:
 - Risks and hazards of a Chemistry Lab
 - Risks and hazards of a Laser Lab
 - Risks and hazards of a Vacuum Lab













Using the platform – A guide

User General Safety Training

General Access to Booking Tool and CRR (However – no booking yet possible)





Process Flow Application





Submits Process Steps / MSDS etc.

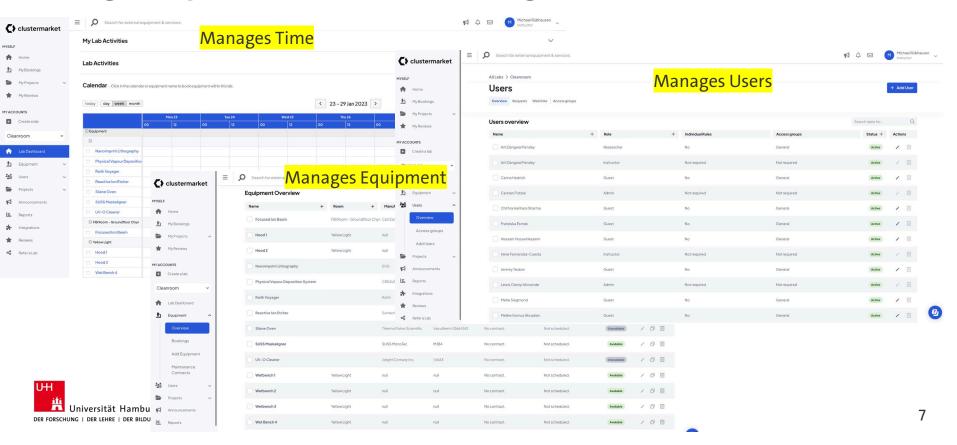




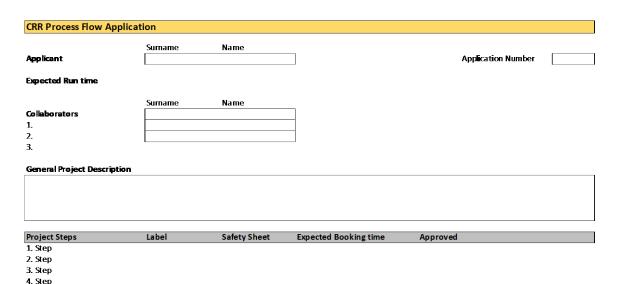


- CRR provides information on the available tools SOP's and standards
- User is now visible for the instructors
- User can contact responsible persons
- User receives information on the process flow applications process
- Users submit their process flow applications. The include MSDS risk assessments.
- Instructors review the application and provide feedback.
- Modifications of tools might be also initiated.

Using the platform – The Booking Tool



Using the platform – The Process Flow Application



- CRR provides information on the available tools SOP's and standards
- User is visible for the instructors
- User can contact responsible persons
- User receives information on the process flow applications process
- The process flow applications detects incompatible process steps and can correct them
- This is not a scientific evaluation just a technical one



Contact



Dr. Ing. Lewis Akinsinde (from 01.04.2024)

Coordinator Technology Platform Clean Room Universität Hamburg

+49 40 8998-6607 lakinsin@physik.uni-hamburg.de

Prof. Dr. Michael Rübhausen

Speaker of the Clean Room Board Fachbereich Physik - Universität Hamburg

+49 40 8998-6600 ruebhausen@physnet.uni-hamburg.de

